

Our Docket No: 42P19023

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Donghui Lu)	Examiner: Stouffer, Kelly M.
)	
Application No: 10/811,591)	Art Unit: 1792
)	
Filed: March 29, 2004)	Confirmation No: 2696
)	
For: Enhanced Dielectric Layers Using)	
Sequential Deposition)	
_____)	

SUBSTITUTE RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Notice of Non-Compliant Amendment mailed May 8, 2009 and in response to the Office Action mailed December 3, 2008, Applicants respectfully request the Examiner to enter the following amendment and to consider the following remark. This Response replaces the one filed on February 10, 2009.

CERTIFICATE OF EFS Web

I hereby certify that this correspondence is being submitted electronically via EFS Web on the date shown below to the United States Patent and Trademark Office.

Date of Deposit:	<u>May 18, 2009</u>
Name of Person Mailing Correspondence:	<u>Debbie Casias</u>
<u>/Debbie Casias/</u>	<u>/ May 18, 2009 /</u>
Signature	Date